

1. In the Hall Effect, the electric field is in x direction and the velocity is in y direction. What is the direction of the magnetic field? *

- ☐ B. Y
- ☐ A. X
- ☒ C. Z
- ☐ D. XY plane

2. What is the conductivity when the Hall Effect coefficient is 5 and mobility is $5\text{cm}^2/\text{s}$. *

- ☐ B. 10 S/m
- ☐ D. 0.01 S/m
- ☐ A. 100 S/m
- ☒ C. 0.0001S/m

3. Hall Coefficient R_h is equal to ratio of hall voltage multiply by width to ----- *

- ☒ C. Electric field and magnetic field
- ☐ D. Current density
- ☐ B. Electric field and length
- ☐ A. Magnetic field and length



4. Electric field E in Hall effect is equals to ----- *

- ☐ C. Hall voltage + semiconductor thickness
- ☒ B. Hallvoltage / semiconductor thickness
- ☐ D. Hall voltage – semiconductor thickness
- ☐ A. Hall voltage x semiconductor thickness

5. If metal or semiconductor carrying current is placed in a magnetic field perpendicular to current, an electric field is induced in direction perpendicular to both current and magnetic field. This phenomena is known as ----- *

- ☐ B. Toxicity
- ☐ A. Chemical effect
- ☐ D. Blister
- ☒ C. Hall effect

6. Light dependent resistor is----- *

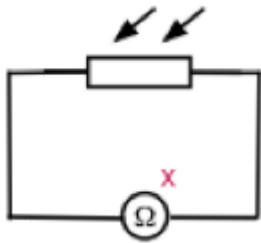
- ☐ D. Photo acoustic
- ☐ C. Photo emissive device
- ☐ B. Photo voltaic device
- ☒ A. Photo resistive device



7. LDR is made up of ----- *

- ☐ B. Low resistance semiconductor
- ☐ C. High resistance metal
- ☒ D. High resistance semiconductor
- ☐ A. Low resistance metal

8. The diagram shows the apparatus used for measuring the resistance of an LDR at different levels of brightness. What device is placed at X? *



- ☐ A. Ammeter
- ☐ D. Thermometer
- ☐ B. Voltmeter
- ☒ C. Ohmmeter

9. A device whose resistance changes with the amount of light shining on it is known as----- *

- ☐ B. A diode
- ☐ C. An electromagnet
- ☐ D. A LED
- ☒ A. An LDR



10. In a light-dependent resistor the resistance decreases as the light intensity --
----. *

- ☐ D. nearly zero
- ☐ A. Decreases
- ☐ C. Constant
- ☒ B. Increases

11. The current flowing through an insulating medium is called *

- ☐ A. Conduction
- ☐ C. Radiation
- ☐ D. Susceptibility
- ☒ B. Convection

12. What is the value of kT at room temperature? *

- ☐ B. 0.25eV
- ☐ C. 25eV
- ☐ D. 0.0025eV
- ☒ A. 0.0256eV



13. The band gap for semiconductor is *

- ☒ A. $2k (2.303 \log_e R/(1/T))$
- ☐ C. $2k (2.303 \log_e RT/ T)$
- ☐ D. $2 (2.303 \log_e RT/ 1/T)$
- ☐ 0

14. The resistance of a conductor increases with an increase in *

- ☐ C. Cooling rate
- ☒ B. Temperature
- ☐ A. Pressure
- ☐ D. resistance

15. Apparatus used to determine the bandgap in Post Office Box method *

- ☐ B. Voltmeter & Daniel cell
- ☒ C. Thermometer & Galvanometer
- ☐ D. High resistance & Daniel cell
- ☐ A. Ammeter & High resistance

16. The value of Boltzmann constant $k =$ _____ *

- ☐ B. $1.380649 \times 10^{+23} \text{ J} \cdot \text{K}^{-1}$.
- ☒ A. $1.380649 \times 10^{-23} \text{ J} \cdot \text{K}^{-1}$.
- ☐ D. $1.380649 \times 10^{+23} \text{ eV}$
- ☐ C. $1.380649 \times 10^{-23} \text{ eV}$.



17. In four probe method, the effect of temperature on _____ is measured.

*

- ☐ B. Voltage
- ☐ D. Flow of electrons
- ☒ C. Resistance
- ☐ A. Current

18. _____ is used to measure the temperature, in four probe method. *

- ☒ C. Thermometer
- ☐ B. Thermocouple
- ☐ A. Thermistor
- ☐ D. Potentiometer

19. The size of the semiconductor used to measure the band gap by four probe method is _____ *

- ☐ A. m
- ☐ D. nm
- ☒ C. mm
- ☐ B. cm



20. The aim of four probe method is, to measure _____ of the semiconductor. *

- ☒ D. Bandgap
- ☐ B. Temperature
- ☐ C. Conductivity
- ☐ A. Resistance

21. The voltage of a single solar cell is *

- ☒ A. 0.5 V
- ☐ D. 5 W.
- ☐ C. 1.1 V
- ☐ B. 1 V

22. Which of the following material is used in solar cells? *

- ☐ A. Barium
- ☒ B. Silicon
- ☐ C. Silver
- ☐ D. Selenium



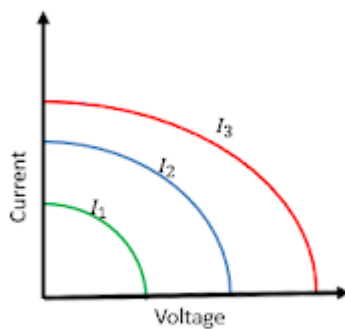
23. The output of a solar cell is of the order of *

- ☐ B. 0.5 W
- ☐ D. 5 W
- ☐ A. 0.1 W
- ☒ C. 1 W

24. Photovoltaic cells are also termed as *

- ☐ C. Volta cell
- ☐ B. Battery cell
- ☒ A. Solar cell
- ☐ D. Rechargeable cell

25. In the below given photocell characteristics, I_1, I_2, I_3 are intensities for 3 different illumination of light. Which of the following is true ? *



- ☐ A. $I_1 > I_2 > I_3$
- ☐ B. $I_1 = I_2 = I_3$
- ☒ C. $I_1 < I_2 < I_3$
- ☐ D. $I_2 > I_1 > I_3$

26. Reading corresponding Illumination characteristics of a photo cell is given below. The value of A is _____. *

Distance between the photocell and light source(cm)	Voltage in the Voltmeter(V)
20	0.16
30	0.11
11	A
40	0.09

- ☒ C. 0.20 V
- ☐ B. 0.09 V
- ☐ A. 0.11 V
- ☐ D. 0.08 V

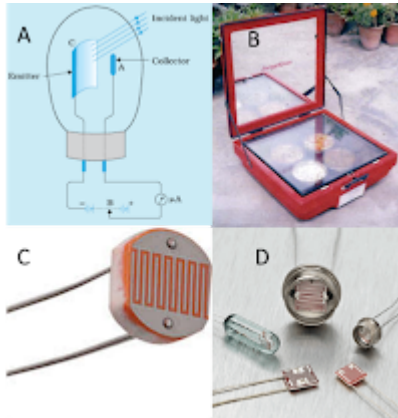
27. Reading corresponding Illumination characteristics of a photo cell is given below. The value of B is _____. *

Distance between the photocell and light source(cm)	Voltage in the Voltmeter(V)
24	0.16
35	0.11
B	0.33
40	0.09

- ☐ D. 50 cm
- ☐ C. 45 cm
- ☒ B. 15 cm
- ☐ A. 25 Cm



28. Which in the following figure is not a Photocell ? *



- ☐ C. C and D
- ☐ A. B
- ☒ D. A
- ☐ B. C

29. The unit of radius of the dark ring represented in terms of *

- ☒ B. Centimetre
- ☐ D. Farad
- ☐ A. Henry
- ☐ C. Ohm

30. In the particle size experiment as the distance (D) increases the radius of the dark ring *

- ☐ C. Constant
- ☒ A. Increases
- ☐ D. First decreases and then increases
- ☐ B. Decreases



31. The reduction in amplitude and intensity of a signal as it guided through an optical fiber is called *

- ☐ C. Power
- ☐ B. Numerical aperture
- ☐ D. Intensity
- ☒ A. Attenuation

32. An is a thin flexible transparent medium of cylindrical or rectangular shape usually made of glass or plastic through which light can be propagated . *

- ☒ D. Optical Fiber
- ☐ A. Antenna
- ☐ B. Cladding
- ☐ C. Transmission line

33. The unit of attenuation is : *

- ☐ B. Bel
- ☐ C. OWU
- ☒ A. Decibel
- ☐ D. No unit



34. The attenuation ,if the output power is same as that of input power is : *

- ☒ B. 0
- ☐ D. -1
- ☐ A. 1
- ☐ C. Infinity

35. The main reason why electrons can tunnel through a PN junction is that *

- ☐ B. They have high energy
- ☐ A. Barrier potential is very low
- ☐ C. Impurity level is low
- ☒ D. Depletion layer is extremely thin

36. Forward biasing of P-N junction: *

- ☐ A. Increases its resistance
- ☐ C. Shorts the junction
- ☐ D. Increases potential difference
- ☒ B. Decreases its resistance

37. When PN junction is in forward bias, by increasing the battery voltage *

- ☒ B. Current through P-N junction increases
- ☐ D. None of the above happens
- ☐ A. Circuit resistance increases
- ☐ C. Current through P-N junction decreases



38. In a PN junction when the applied voltage overcomes the potential, the diode current is large, which is known as *

- ☐ B.Reverse, reverse bias
- ☐ A.Depletion, negative bias
- ☐ C.Resistance, reverse bias
- ☒ D.Barrier, forward bias

39. Calculate Fill factor using the data: $P_{max}=15\text{ W}$, $V_{oc}=18\text{ V}$, $I_{sc}=4\text{ A}$. *

- ☐ B. 0.59
- ☒ C. 0.20
- ☐ D. 0.98
- ☐ A. 0.65

40. The solar or photo voltaic cell converts energy from *

- ☐ D. Thermal into electrical
- ☐ C. Solar radiation into thermal
- ☒ B. Solar radiation into electrical
- ☐ A. Chemical to electrical



41. Photovoltaic cells can operate when the incident photons have *

- ☐ D. Frequencies below visible light
- ☐ C. Microwave frequencies
- ☐ B. Infra-red frequencies
- ☒ A. Frequencies above visible light

42. When a PN junction is reverse biased *

- ☒ C. Holes and electrons tend to move away from the junction
- ☐ B. The barrier tends to break down
- ☐ A. Holes and electrons tend to concentrate towards the junction
- ☐ D. None of these

43. X-rays are by atoms when they strike the surface of a crystal *

- ☐ A. Completely scattered
- ☐ B. Partially reflected
- ☐ C. Completely reflected
- ☒ D. Partially diffracted

44. Why the X-rays are used to determine the crystal structures *

- ☐ D. The wavelength of x-rays is smaller than the distance of inter atomic spac
- ☒ A. The wavelength of x-rays is equal to the distance of inter atomic spacing
- ☐ B. The wavelength of x-rays is not equal to the distance of inter atomic spacing
- ☐ C. The wavelength of x-rays is higher than the distance of inter atomic spacing



45. When x-ray beams diffracted by two different layers are in phase, occurs and the diffraction pattern shows a peak *

- ☐ D. completely plane polarization
- ☒ C. constructive interference
- ☐ B. total internal reflection
- ☐ A. destructive interference

46. What kind of diffraction pattern do the amorphous materials show up? *

- ☐ C. no peaks
- ☐ B. medium peaks
- ☐ D. very sharp peaksu
- ☒ A. sharp peaks

47. One that is based on forward biased PN junction is *

- ☒ A. LED
- ☐ B. Photo diode
- ☐ D. Photo electric effect
- ☐ C. Photo voltaic cell



48. Which of the following statement is not true about photo cell? *

- ☐ B. No power cables are needed
- ☐ C. Do not produce polluting waste
- ☒ D. They work at night
- ☐ A. No fuel is needed

49. For a good quality of optical Fiber the desirable numerical aperture is : *

- ☐ C. Zero
- ☐ D. Infinity
- ☐ A. Low
- ☒ B. High

50. As PN junction is Forward biased *

- ☒ C. The barrier tends to breakdown
- ☐ B. The depletion region decreases
- ☐ D. The terminals get opposite
- ☐ A. Holes as well as electrons tend to drift away from the junction.

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